

FLL410IK-3C

L-Band High Power GaAs FET

FEATURES

- High Output Power: $P_{out}=46.0\text{dBm(Typ.)}$
- High Gain: $GL=13.0\text{dB(Typ.)}$
- High PAE: $\eta_{add}=52\%\text{(Typ.)}$
- Broad Band: 2.5~2.7GHz
- Hermetically Sealed Package

DESCRIPTION

The FLL410IK-3C is a partially matched 40 Watt GaAs FET that is designed for use in 2.5 – 2.7 GHz band amplifiers. This new product is uniquely suited for use in MMDS applications as it offers excellent linearity, high efficiency, high gain, long term reliability and ease of use.



Fujitsu's stringent Quality Assurance Program assures the highest reliability and consistent performance.

ABSOLUTE MAXIMUM RATINGS (Case Temperature $T_c=25^\circ\text{C}$)

Item	Symbol	Rating	Unit
Drain-Source Voltage	V_{DS}	15	V
Gate-Source Voltage	V_{GS}	-5	V
Total Power Dissipation	PT	100	W
Storage Temperature	T_{stg}	-65 to +175	$^\circ\text{C}$
Channel Temperature	T_{ch}	175	$^\circ\text{C}$

RECOMMENDED OPERATING CONDITION(Case Temperature $T_c=25^\circ\text{C}$)

Item	Symbol	Condition	Limit	Unit
DC Input Voltage	V_{DS}		≤ 12	V
Gate Current	I_{GF}	$R_G=5\Omega$	≤ 88	mA
Gate Current	I_{GR}	$R_G=5\Omega$	≥ -25	mA
Operating Channel Temperature	T_{ch}		≤ 145	$^\circ\text{C}$

ELECTRICAL CHARACTERISTICS (Case Temperature $T_c=25^\circ\text{C}$)

Item	Symbol	Test Conditions	Limit			Unit
			Min.	Typ.	Max.	
Drain Current	I_{DSS}	$V_{DS}=5\text{V}, V_{GS}=0\text{V}$	-	4.0	-	A
Pinch-off Voltage	V_p	$V_{DS}=5\text{V}, I_{DS}=110\text{mA}$	-0.1	-0.3	-0.5	V
Gate-Source Breakdown Voltage	V_{GSO}	$I_{GS}=-1.1\text{mA}$	-5.0	-	-	V
Output Power	P_{OUT}	$V_{DS}=12\text{V}$ $f=2.6\text{GHz}$ $I_{DS}=3\text{A}$ $P_{in}=35.0\text{dBm}$	45.0	46.0	-	dBm
Linear Gain *1	GL		12.0	13.0	-	dB
Drain Current	I_{DSR}		-	5.9	7.6	A
Power-added Efficiency	η_{add}		-	52	-	%
Thermal Resistance	R_{th}	Channel to Case	-	1.3	1.5	$^\circ\text{C/W}$

* 1 : GL is measured at $P_{in}=22.0\text{dBm}$

CASE STYLE: IK

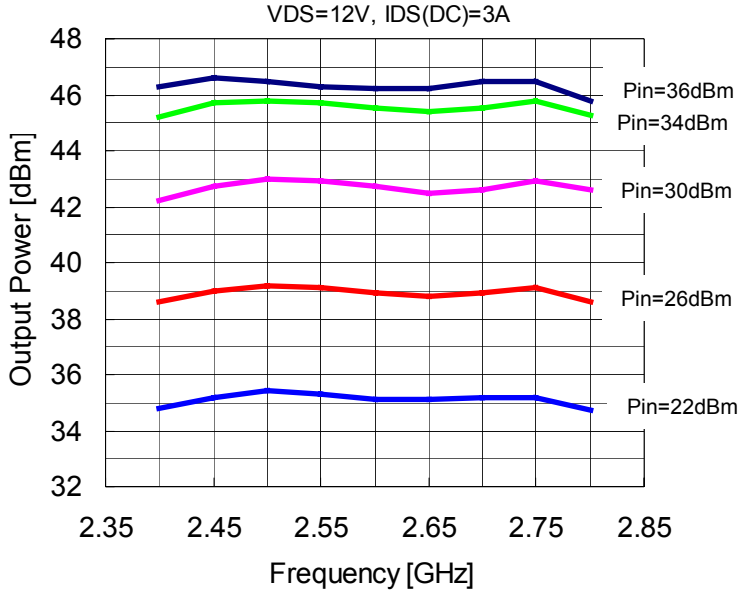
E5D	Class III	2000V ~
-----	-----------	---------

Note : Based on EIAJ ED-4701 C-111A(C=100pF, R=1.5k Ω)

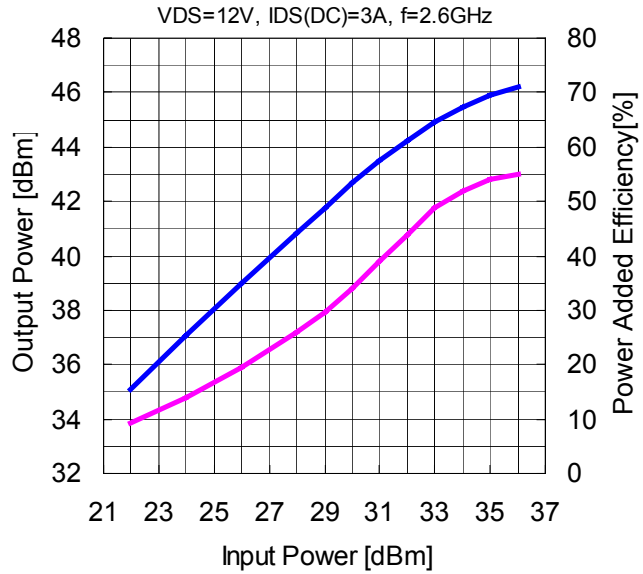
FLL410IK-3C

L-Band High Power GaAs FET

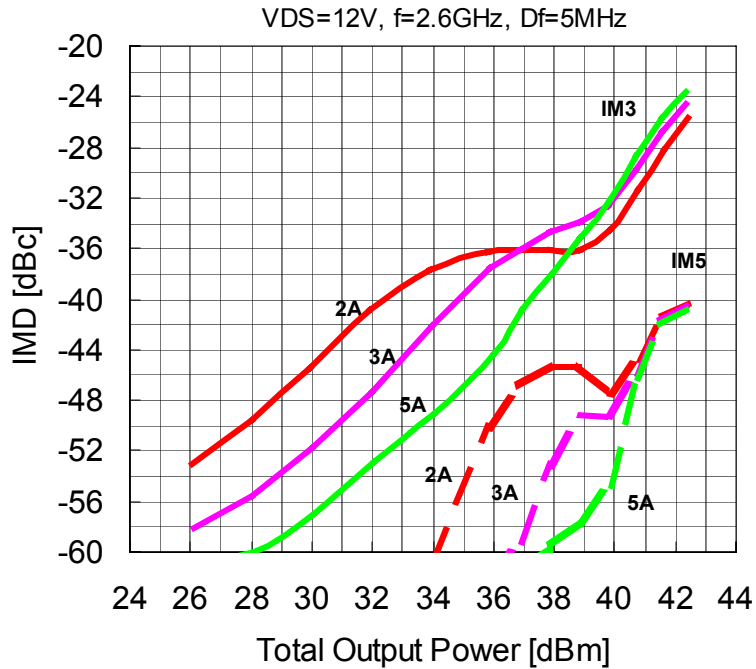
OUTPUT POWER vs. INPUT POWER



OUTPUT POWER, POWER ADDED EFFICIENCY vs. TOTAL INPUT POWER



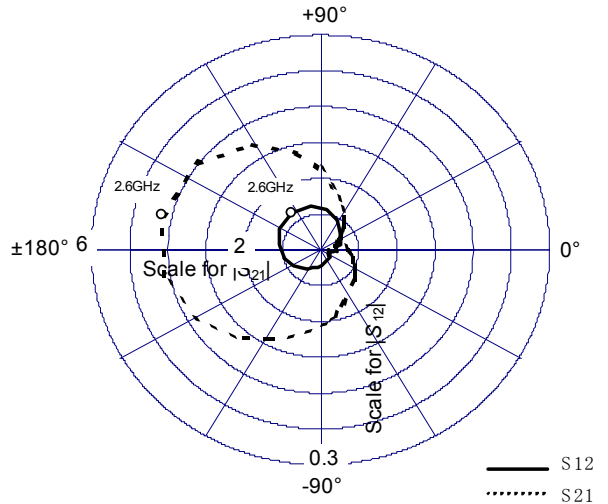
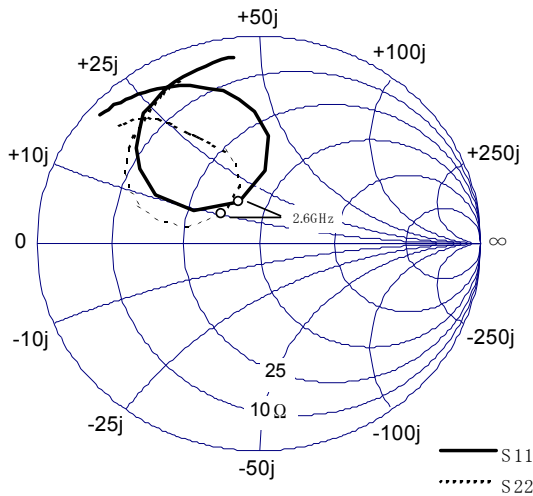
IMD vs. TOTAL OUTPUT POWER



FLL410IK-3C

L-Band High Power GaAs FET

■ S-PARAMETER



VDS=12V, IDS=3.0A

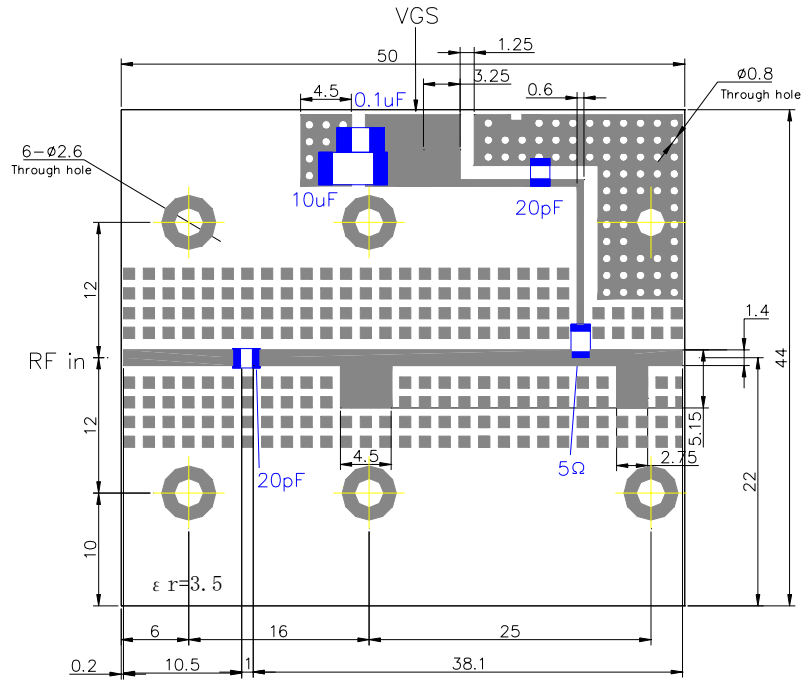
Freq [GHz]	S11		S21		S12		S22	
	MAG	ANG	MAG	ANG	MAG	ANG	MAG	ANG
1.50	0.95	139.13	0.66	5.71	0.01	-7.76	0.85	137.80
1.60	0.94	136.13	0.73	-1.34	0.01	-21.24	0.83	134.28
1.70	0.92	132.48	0.83	-11.38	0.01	-27.54	0.80	130.79
1.80	0.91	129.08	0.93	-21.69	0.01	-37.64	0.76	127.82
1.90	0.89	125.19	1.08	-33.36	0.01	-48.85	0.72	125.28
2.00	0.87	121.65	1.26	-45.28	0.01	-64.79	0.68	122.79
2.20	0.83	112.20	1.82	-76.40	0.02	-97.72	0.61	119.58
2.30	0.78	106.32	2.27	-95.83	0.02	-122.75	0.57	117.16
2.40	0.70	97.54	2.86	-118.23	0.03	-148.63	0.52	112.58
2.50	0.52	85.55	3.75	-149.12	0.04	173.08	0.40	105.59
2.60	0.22	114.34	4.29	166.53	0.04	127.14	0.22	139.17
2.70	0.52	153.17	3.43	121.10	0.04	82.29	0.47	165.62
2.80	0.72	139.88	2.23	89.90	0.03	50.87	0.65	155.17
2.90	0.82	129.39	1.54	71.09	0.02	27.82	0.72	145.97
3.00	0.85	121.63	1.10	57.03	0.02	15.34	0.76	138.08
3.10	0.87	116.02	0.87	45.39	0.01	-3.89	0.79	130.98
3.20	0.88	110.41	0.66	35.06	0.01	-7.86	0.82	125.09
3.30	0.89	105.71	0.56	28.49	0.01	-16.93	0.84	120.80
3.40	0.90	100.75	0.47	20.22	0.01	-25.52	0.86	117.16
3.50	0.91	97.00	0.42	15.07	0.01	-22.89	0.86	113.34

FLL410IK-3C

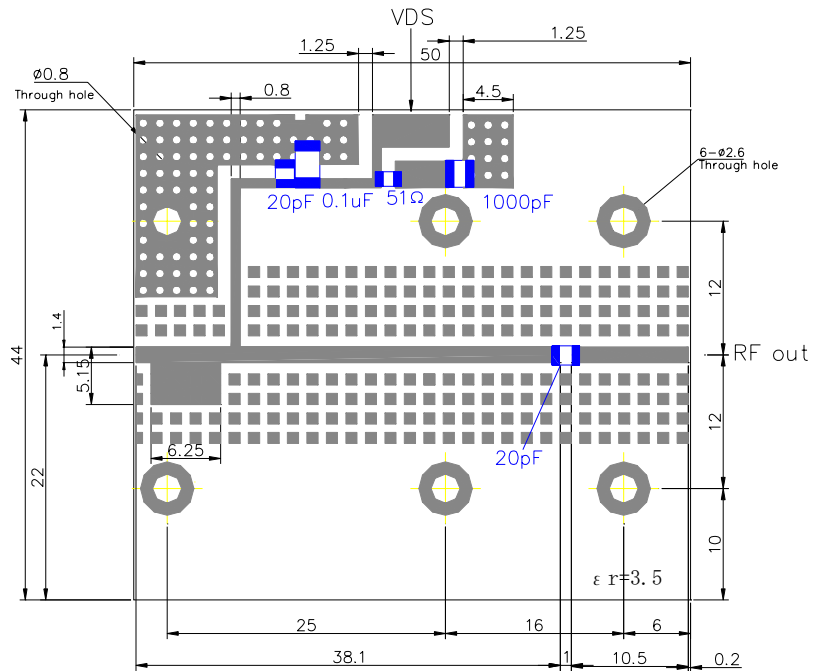
L-Band High Power GaAs FET

■ BOARD LAYOUT(Reference)

<INPUT SIDE>



<OUTPUT SIDE>

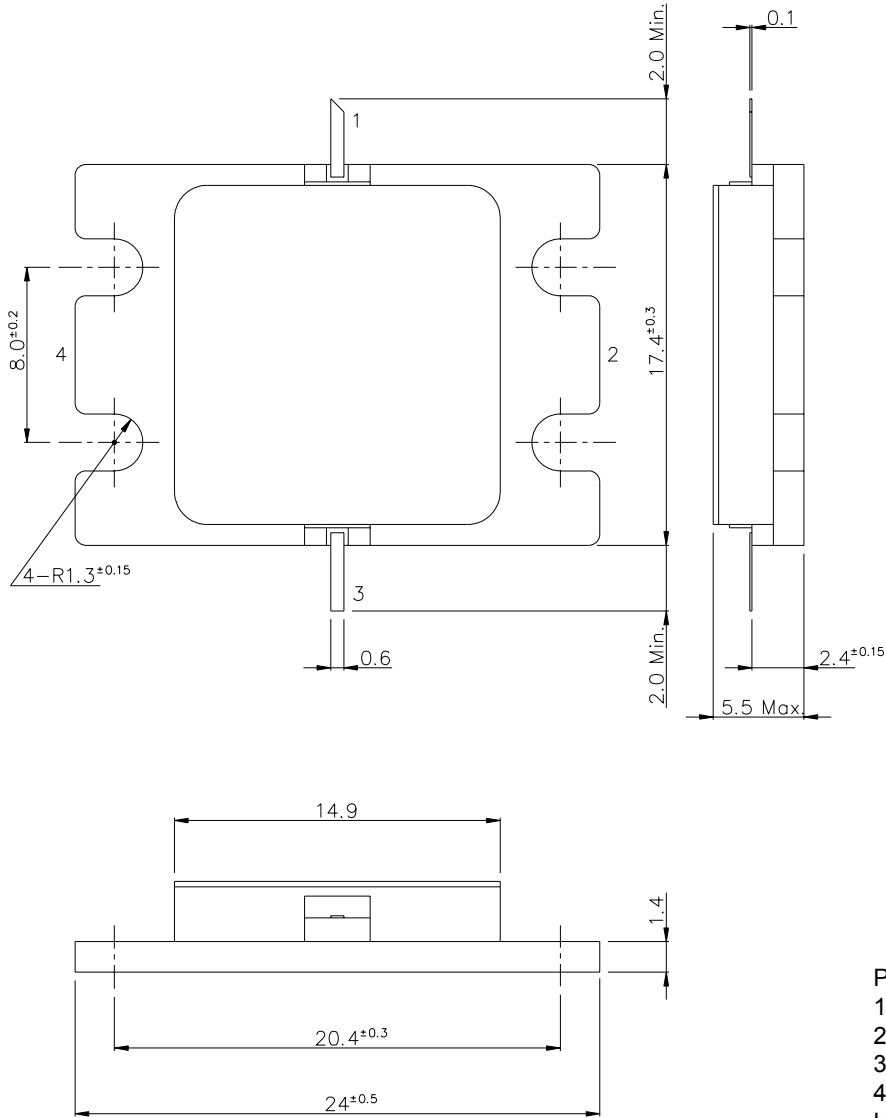


$\epsilon_r=3.5$, $t=0.6\text{mm}$
Unit : mm

FLL410IK-3C

L-Band High Power GaAs FET

■ Package Out Line



FLL410IK-3C

L-Band High Power GaAs FET

For further information please contact :

FUJITSU COMPOUND SEMICONDUCTOR, INC.

2355 Zanker Rd.
San Jose, CA 95131-1138, U.S.A.
TEL: (408) 232-9500
FAX: (408) 428-9111
www.fcsi.fujitsu.com

FUJITSU QUANTUM DEVICES EUROPE LTD.

Network House
Norreys Drive
Maidenhead, Berkshire SL6 4FJ
TEL: +44 (0) 1628 504800
FAX: +44 (0) 1628 504888

FUJITSU QUANTUM DEVICES SINGAPORE PTE LTD.

HONG KONG BRANCH
Rm. 1101, Ocean Centre, 5 Canton Rd.
Tsim Sha Tsui, Kowloon, Hong Kong
TEL: +852-2377-0227
FAX: +852-2377-3921

FUJITSU QUANTUM DEVICES LTD.

1000 Kamisukiahara, showa-cho
Nakakomagun, Yamanashi
409-3883, Japan
(Kokubo Industrial Park)
TEL: +81-55-275-4411
FAX: +81-55-275-9461

FUJITSU QUANTUM DEVICES LIMITED

Business Development Division
Hachioji Daiichi-Seimei Bldg., 11th Floor
3-20-6 Myojin-cho
Hachioji-city, Tokyo 192-0046, Japan
TEL: +81-426-43-5885
FAX: +81-426-43-5582

Fujitsu Limited reserves the right to change products and specifications without notice.
The information does not convey any license under rights of Fujitsu Limited or others.

© 2004 FUJITSU COMPOUND SEMICONDUCTOR, INC.
Printed in U.S.A.

CAUTION

Fujitsu Compound Semiconductor Products contain **gallium arsenide (GaAs)** which can be hazardous to the human body and the environment. For safety, observe the following procedures:

- Do not put these products into the mouth.
- Do not alter the form of this product into a gas, powder, or liquid through burning, crushing, or chemical processing as these by-products are dangerous to the human body if inhaled, ingested, or swallowed.
- Observe government laws and company regulations when discarding this product. This product must be discarded in accordance with methods specified by applicable hazardous waste procedures.

The Fujitsu logo consists of the word "FUJITSU" in a bold, red, sans-serif font. Above the letter "I" is a red infinity symbol (∞). A horizontal red line extends from the right side of the "FUJITSU" text across the page.